



Contact information

David Gino  
1-512-339-7760  
dgino@molecularimprints.com

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**MOLECULAR IMPRINTS ANNOUNCES THE RETIREMENT OF NORMAN SCHUMAKER; MARK MELLIAR-SMITH PROMOTED TO CEO**

AUSTIN, TX. October 17, 2005 – - Molecular Imprints, Inc. (MII), the world leader in imprint lithography, today announced that Dr. Norman Schumaker, President and CEO, has stepped down to enter retirement. Mark Melliar-Smith, MII's Chief Operating Officer, has been appointed CEO.

Dr. Schumaker has been associated with Molecular Imprints since its inception and provided the seed capital to start the company with Grant Willson and S.V. Sreenivasan, who are professors at the University of Texas at Austin. MII has raised \$60 million of equity financing and has filed over 300 patents worldwide.

"I am very proud of the leadership position that MII has achieved within imprint lithography during my tenure," said Schumaker. "I look forward to watching the company's continued success."

Mark Melliar-Smith comments, "Norm was instrumental in the formation of MII in the year 2000, and he navigated the company through its initial product development and fund raising activities. Norm's passion for MII's technology, its broad range of market opportunities, and the company's excellent staff have shaped the culture of Molecular Imprints. I am determined to build upon this foundation."

Mark Melliar-Smith joined MII in April 2004 as COO. He has over 30 years of experience in the semiconductor industry and has served as President and CEO of International SEMATECH as well as Chief Technical Officer of Lucent Technologies Microelectronics, the forerunner of Agere Systems. Prior to joining MII, Melliar-Smith was a venture partner with Austin Ventures, a venture capital company. Melliar-Smith is a member of the board of directors of Technitrol (TNL), Power-One (PWER), and Metrosol, a privately held company.

**About Molecular Imprints Inc.**

Molecular Imprints, Inc. (MII) is a global developer and manufacturer of nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized a proprietary imprint lithography technology (S-FIL™), which is a room temperature, low pressure, non-contact imprint process that has demonstrated sub-20 nanometer resolution. Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of nano-devices, solid state lighting, silicon applications, micro optical components, and magnetic data storage applications. For more information, visit

[www.molecularimprints.com](http://www.molecularimprints.com).

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